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Publisher Correction: Enhanced generation and anisotropic Coulomb scattering of hot electrons in an ultra-broadband plasmonic nanopatch metasurface

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The originally published version of this Article contained an error in Equation 1. The two $\hbar$ terms were missing from this equation, which incorrectly read:

$$\text{Rate}_{\text{nonthermal}} = \sum_{i=\text{Ag,Au}} \frac{2e^2 E_{F,i}^2}{\pi^2 (\omega)^3} \int_{S_{\text{NC},i}} |E_n(\theta, \varphi)|^2 dS,$$

The correct form of Equation 1 is as follows:

$$\text{Rate}_{\text{nonthermal}} = \sum_{i=\text{Ag,Au}} \frac{2e^2 E_{F,i}^2}{\pi^2 \hbar (\hbar\omega)^3} \int_{S_{\text{NC},i}} |E_n(\theta, \varphi)|^2 dS,$$

This has now been corrected in the PDF and HTML versions of the Article.

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